

Attorney's Docket No.: 09712-332001 / Z-433

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant

: Peter J. de Groot

Art Unit : 2877

Serial No. : 10/659,060

Examiner : Marissa Detschel

Filed

: September 9, 2003

Title

: INTERFEROMETRY METHOD FOR ELLIPSOMETRY, REFLECTOMETRY, AND

SCATTEROMETRY MEASUREMENTS, INCLUDING CHARACTERIZATION OF

THIN FILM STRUCTURES

MAIL STOP AMENDMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

INFORMATION DISCLOSURE STATEMENT

Applicants request consideration of the references listed on the attached PTO-1449 form. Under 37 C.F.R. § 1.98 (a)(2)(ii), only copies of foreign patent documents and/or non-patent literature are enclosed. Copies of any listed U.S. patents or U.S. patent application publications can be provided upon request.

This statement is being filed after a first Office action on the merits, but before receipt of a final Office action or a Notice of Allowance. A check for \$180 in payment of the late submission fee of §1.17(p) is enclosed. Please apply any other charges or credits to Deposit Account No. 06-1050, referencing 09712-332001.

Respectfully submitted,

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Substitute	Form	PTO-1449
(Modified)		

U.S. Department of Commerce Patent and Trademark Office Attorney's Docket No. 09712-332001

Applicant

Application No. 10/659,060

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Information Disclosure Statement by Applicant (Use several sheets if necessary)

(37 CFR §1.98(b))

Peter J. de Groot Filing Date September 9, 2003

Group Art Unit 2877

_	TRADEMARY

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Examiner Initial	Desig. ID	Document Number	Publication Date	Patentee	Class	Subclass	Filing Date If Appropriate
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	AB	5,129,724	07/14/1992	Brophy et al.	356	357	
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	AY	2006/0012582	01/19/2006	de Lega			
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	AAA						

Examiner Signature

Date Considered

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Substitute Form PTO-1449 U.S. Department of Commerce (Modified) Patent and Trademark Office		Attorney's Docket No. 09712-332001	Application No. 10/659,060
	closure Statement pplicant	Applicant Peter J. de Groot	
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	Foreign Patent Documents or Published Foreign Patent Applications							
Examiner	Desig.	Document	Publication	Country or			Transla	ation
Initial	ID	Number	Date	Patent Office	Class	Subclass	Yes	No
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	D1	sampling window", <u>Appl. Opt.</u> , 34(22), p. 4723-4730 (1995)			

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	DI			

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